## University of Oslo Faculty of Mathematics and Natural Sciences

Final Exam in: Special Syllabus Lukasz Farian, fall 2013

Date of exam: 18-Dec-2013

Time: 9:00-13:00

This examination paper consists of 2 page(s)

Permitted materials: All printed and written including

approved (!) calculator

Make sure that your copy of this examination paper is complete before answering.

## Read Carefully:

This is an extra question in addition to the exam in INF3410, fall 2013, for the special syllabus for Lukasz Farian  $\,$ 

Each question is graded indicating the weight when grading.

## Chapter 7

The circuit in figure 1 is implemented in the  $0.35\mu m$  technology of table 1 with  $L_{1,2}=1\mu m$ .

Task 11 (3p): Find  $W_1, W_2$  and R so that  $V_{eff1,2}{=}300 mV$  and  $I_D{=}25\mu A$ 

Task 12 (3p): How much will  $I_D$  change if both  $V_{tn}$  and  $|V_{tp}|$  increase by 20%?

 Table 1.5
 MOSFET parameters representative of various CMOS technologies and used for rough hand calculations in this text.

	0.8 μm		0.35 μm		0.18 μm		45 nm	
Technology	NMOS	<b>PMOS</b>	NMOS	<b>PMOS</b>	NMOS	<b>PMOS</b>	NMOS	<b>PMOS</b>
$\mu C_{ox} \ (\mu A/V^2)$	92	30	190	55	270	70	280	70
$V_{t0}$ (V)	0.80	-0.90	0.57	-0.71	0.45	-0.45	0.45	-0.45
$\lambda \cdot \text{L}  (\mu \text{m/V})$	0.12	0.08	0.16	0.16	0.08	0.08	0.10	0.15
$C_{ox}\ (fF/\mu m^2)$	1.8	1.8	4.5	4.5	8.5	8.5	25	25
$t_{ox}$ (nm)	18	18	8	8	5	5	1.2	1.2
n	1.5	1.5	1.8	1.7	1.6	1.7	1.85	1.85
θ (1/V)	0.06	0.135	1.5	1.0	1.7	1.0	2.3	2.0
m	1.0	1.0	1.8	1.8	1.6	2.4	3.0	3.0
$C_{ov}/W = L_{ov}C_{ox}$ $(fF/\mu m)$	0.20	0.20	0.20	0.20	0.35	0.35	0.50	0.50
$C_{db}/W \approx C_{sb}/W$ $(fF/\mu m)$	0.50	0.80	0.75	1.10	0.50	0.55	0.45	0.50

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Table 1: Typical process parameters

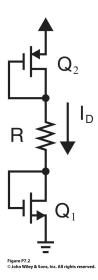


Figure 1: A simple circuit to produce a bias current